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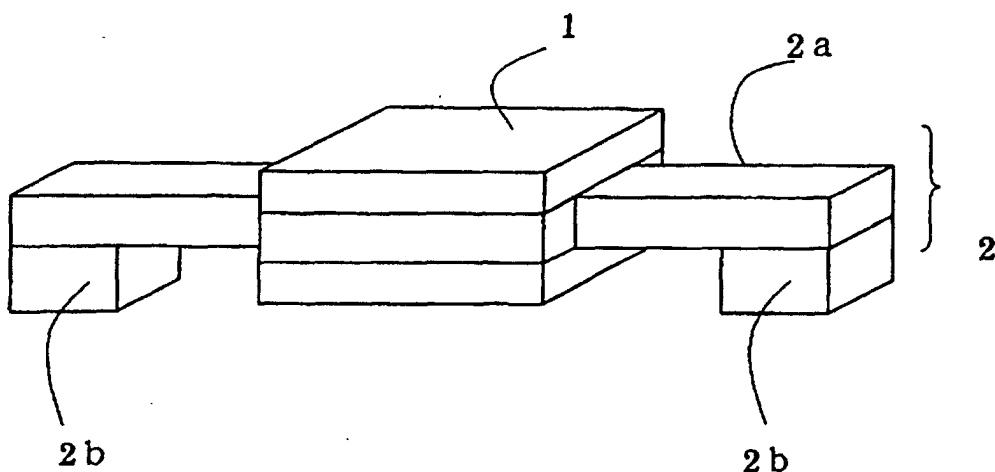
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(54) **HYDROSTATIC GAS BEARING, HYDROSTATIC GAS BEARING DEVICE FOR USE IN VACUUM ENVIRONMENT, AND GAS RECOVERING METHOD FOR THE HYDROSTATIC GAS BEARING DEVICE**

(57) In a hydrostatic gas bearing for use in a vacuum, in order to provide a hydrostatic gas bearing in which an increase in the quantity of gas being discharged during the movement of a moving body is reduced, the surface of a guide shaft of a fixed body and/

or the surface of the moving body is subjected to processing for reducing adhesion of gas molecules, for example, by coating the surface(s) with a material having a low adhesion probability of gas molecules, by which the quantity of gas being discharged is decreased.

FIG. 1



Description

Technical Field

[0001] The present invention relates to a hydrostatic gas bearing for use in a vacuum, a hydrostatic gas bearing device incorporating the hydrostatic gas bearing, and a gas recovering method for the hydrostatic gas bearing device.

Background Art

[0002] Conventionally, in a hydrostatic gas bearing for use in a vacuum, as a shape accuracy required for a moving body and a fixed body surface opposed to the moving body, only flatness to an extent of not affecting the size of a floating gap and a labyrinth seal gap has been required, and pores in the surface have especially not been considered. Also, in selecting the material of a guide shaft of the fixed body and the material of the moving body, only a property that the quantity of gas being discharged when the material is continuously exposed to a vacuum environment for a fixed period of time or more is small has been considered not to exert an influence on the reached degree of vacuum of mounted equipment.

[0003] Also, a general hydrostatic gas bearing is configured so that a high-pressure gas is released from an air pad provided on the moving body into a gap between the moving body and the fixed body surface, and the moving body and the fixed body are made in a non-contact state by the hydrostatic pressure of released gas, by which the moving body is moved with frictional resistance being scarcely encountered.

[0004] In the hydrostatic gas bearing as described above, in order to maintain the vacuum environment, it is desirable that an atmospheric pressure groove be provided around the air pad, and a mechanism for keeping the gas pressure in the atmospheric pressure groove at the atmospheric pressure be provided.

[0005] The reason for this is that by providing the atmospheric pressure groove around the air pad, even in the design of hydrostatic gas bearing for vacuum, the load capacity, rigidity, and the like of the air pad can be designed by the same design technique as that for the ordinary hydrostatic gas bearing for use in an atmospheric environment.

[0006] Also, when the atmospheric pressure groove is not provided, all gas emitted from the air pad flows into an exhaust pump through a pressure reducing groove, so that the load of the exhaust pump increases undesirably. To prevent this phenomenon, the provision of the atmospheric pressure groove is also effective.

[0007] Therefore, as a mechanism for keeping the pressure in the atmospheric pressure groove at the atmospheric pressure, conventionally, an atmospheric pressure pipe has been connected to the atmospheric pressure groove provided around the air pad, and the

other end of the atmospheric pressure pipe has simply been opened to the atmosphere on the outside of a vacuum chamber.

[0008] For the hydrostatic gas bearing manufactured by using the prior art, even when the quantity of gas discharged from a bearing device is lower than the specified discharge quantity in a stationary state, the quantity of gas discharged from the bearing device increases suddenly at the same time that the moving body starts to move, so that the reached pressure in the vacuum chamber is sometimes deteriorated remarkably. The reason for this is as described below. For example, in the hydrostatic gas bearing provided with the air pad on the moving body side, a portion covered by the moving body of the fixed body surface is exposed to a high-pressure floatation gas in a stationary state, and thus large quantities of gas molecules adhere to that portion. Subsequently, when the moving body moves and the surface thereof is exposed to the vacuum environment, large quantities of gas molecules adhering to the surface of guide shaft are discharged to the outside, which is resultantly detected as a sudden increase in the quantity of gas being discharged.

[0009] When the above-mentioned pressure increase occurs in a hydrostatic gas bearing mounted, for example, in an EB exposure system, a sudden increase in pressure degrades the accuracy of exposure pattern, and sometimes damages the electron beam source.

[0010] A hydrostatic gas bearing constructed so that the air pad is provided on the fixed body side also presents the same problem at the time of movement because gas molecules adhere to the surface of the moving body.

[0011] The inventor started research and development of a hydrostatic gas bearing capable of being used in an environment of higher vacuum (about 10^{-5} Pa). As the result, it was verified that there occurs, on rare occasions, a phenomenon that the gas pressure in the vacuum chamber increases due to the movement of the moving body even from a cause other than the gas supplied to the air pad.

[0012] Thus, in order to determine the cause and to provide a higher-performance hydrostatic gas bearing, the inventor further conducted research and development earnestly.

[0013] For example, in the case of a semiconductor exposure system, the vacuum chamber in which a hydrostatic gas bearing is mounted is usually placed in a clean room whose temperature and humidity are controlled.

[0014] In the hydrostatic gas bearing in which the atmospheric pressure groove in the bearing is simply opened to the atmosphere on the outside of vacuum chamber via the atmospheric pressure pipe, gas usually flows out from the bearing side to the atmosphere side. However, it was found that gas may sometimes flow in inversely from the atmosphere side to the bearing side depending on the pressure balance of the atmospheric

pressure groove fluctuated by the bearing gap etc.

[0015] When gas flows inversely from the atmosphere side to the bearing side as described above, the atmosphere having a specific humidity flows in to the bearing side via the atmospheric pressure groove, and thus large amounts of water molecules undesirably adsorb on the surface of the guide shaft. If the moving body of the bearing starts to move in this state and the guide shaft surface on which water molecules have adsorbed is exposed to a vacuum, the adsorbing water molecules are released into the vacuum environment, which results in an increase in gas pressure in the vacuum chamber.

[0016] Even if the quantity of adsorbing water molecules is minute, when the pressure in the vacuum chamber is a high vacuum of about 10^{-5} Pa, a remarkable increase in pressure is observed. If such an increase in pressure occurs in the bearing, for example, in an electron beam exposure system, the above-mentioned phenomenon may cause a failure of light source and degradation of exposure accuracy.

[0017] In the hydrostatic gas bearing for use in an environment of an especially high vacuum, it is necessary to carry out control so that the causes for the increase in gas pressure in the vacuum chamber are obviated.

Disclosure of the Invention

[0018] The present invention has been made to solve the above problems, and accordingly a first object thereof is to provide a hydrostatic gas bearing in which an increase in the quantity of gas being discharged during the movement of a moving body is reduced.

[0019] To achieve the above first object, the present invention provides a hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to the moving body, characterized in that the surface of a guide shaft of the fixed body and/or the surface of the moving body are subjected to processing for reducing adhesion of gas molecules. Since surface treatment for decreasing the quantity of adhering gas is done on the surface of the guide shaft of the fixed body, the increase in the quantity of gas being discharged during the movement of the moving body is reduced.

[0020] The degree of vacuum in a vacuum chamber is required to be 10^{-3} to 10^{-4} Pa or lower depending on the service conditions. Further, movement in a vacuum environment of about 10^{-5} Pa or lower is also expected in the future.

[0021] In this description, to decrease the quantity of adhering gas molecules means to decrease the quantity of adhering gas molecule so that gas molecules do not adhere to the guide shaft etc. to an extent that the pressure is not increased to an extent that even if adhering gas molecules are released in a vacuum, they do not hinder the use of device in the above-mentioned vacuum environment.

[0022] For example, conventionally, on the surface of

the guide shaft newly exposed by the movement of moving body, gas molecules of about 10^{-6} mole per 1 m^2 adhere at the moment of exposure. These gas molecules are released in the vacuum, exerting an adverse influence on the use of hydrostatic gas bearing in a vacuum environment.

[0023] On the other hand, in the hydrostatic gas bearing in accordance with the present invention, the quantity of adhering gas molecules can be decreased to about 10^{-8} mole per 1 m^2 , so that the use of hydrostatic gas bearing in a vacuum environment is not hindered.

[0024] In the present invention, the subjects to be subjected to the above-mentioned surface treatment are not limited to the surface of the fixed body. The effect of surface treatment can be achieved by subjecting a member exposed to the vacuum environment by the movement, of the bearing constituting members, to treatment immediately after the member is exposed to a high-pressure floatation gas.

[0025] Also, as the surface treatment for decreasing the quantity of adhering gas, the surface of the guide shaft of fixed body and/or the surface of the moving body is coated with a material having a lower adhesion probability of gas. By this method, the adhesion probability of gas on the bearing surface is decreased. Also, pores in a ceramics surface are filled with the coating and thus a smooth surface is formed, so that the quantity of adhering gas molecules is further decreased. For example, by coating an Al_2O_3 surface with TiC by CVD, the quantity of adhering H_2O , which especially poses a problem of adhesion of gas molecules, can be kept about two orders of magnitude smaller.

[0026] Also, since the film of TiC has electric conductivity, for the hydrostatic gas bearing mounted in an EB exposure system, an antistatic effect due to electron can be expected.

[0027] As a preferred mode of the present invention, the guide shaft of fixed body and/or the moving body formed of high-density ceramics having few pores in the surface thereof is manufactured, by which an increase in the quantity of gas being discharged caused by the influence of the above-mentioned pores is reduced.

[0028] Usually, since an infinite number of pores exist in the surface of ceramics, when the surface is exposed to a high-pressure gas, the pores are filled with the gas. Therefore, when the moving body moves and the surface thereof is exposed to a vacuum, the gas filled in the pores is slowly released into the vacuum chamber, so that the reached degree of vacuum of the vacuum chamber is deteriorated. Also, when the ceramics are machined, dirt such as a grinding fluid is liable to remain in the pores, and much gas adheres to the dirt, so that the dirt sometimes becomes a serious gas release source.

[0029] Ceramics having few pores can be obtained by a method in which ceramics are manufactured using fine-grain raw material powder having an average grain size of $1 \text{ }\mu\text{m}$ or smaller, a method in which ceramics are subjected to hot press processing before firing to densify

them, a method in which the ordinary alumina ceramics are subjected to HIP processing, or the like method. It is desirable that the theoretical density of pore area in the ceramics surface be 1% or lower.

[0030] Also, as a floatation gas for hydrostatic gas bearing suitable to the present invention, an inert gas such as argon, which has less interaction with a solid and less adhesion to the surface, is used to decrease the quantity of gas being discharged at the time of movement. When argon is used, since the gas molecular weight is higher than that of the ordinary gas (N_2 and O_2), the conductance of a labyrinth seal becomes low, which achieves an effect of obtaining high sealing performance.

[0031] Also, a second object of the present invention is to provide a hydrostatic gas bearing device for use in a vacuum environment, in which in a device incorporating a hydrostatic gas bearing for use in a vacuum environment, the pressure in an atmospheric pressure groove within the bearing in a vacuum environment is kept fixed, and the inflow of impurities such as water content of gas caused by the backward flow of outside gas into the atmospheric pressure groove through a pipe for atmospheric pressure groove is prevented, by which a decrease in the degree of vacuum in the vacuum environment can be prevented, and a gas recovering method for the hydrostatic gas bearing device.

[0032] To achieve the second object, the present invention provides a hydrostatic gas bearing device for use in a vacuum environment, in which a guide shaft and a moving body moving along the guide shaft are provided in a vacuum chamber; the moving body is formed with an air pad for releasing gas fed from the outside into a gap between the moving body and the guide shaft; an atmospheric pressure groove, which recovers the gas released into the gap and discharges the recovered gas to the outside through a pipe, is provided around the air pad; and a pressure reducing groove, which recovers the gas having not been recovered by the atmospheric pressure groove and discharges the recovered gas to the outside through a pipe, is provided around the atmospheric pressure groove, characterized in that in a pipe for discharging the gas recovered through the atmospheric pressure groove to the outside, there is provided a pressure buffering chamber, in which the internal gas pressure thereof is a fixed pressure higher than the atmospheric pressure so that gas does not flow backward from the outside to the atmospheric pressure groove through the pipe.

[0033] Thereby, the inflow of impurities such as water content of gas caused by the backward flow of outside gas into the atmospheric pressure groove within the bearing through the pipe is inhibited, by which a decrease in the degree of vacuum in the vacuum environment can be prevented.

[0034] In particular, in the hydrostatic gas bearing for use in a high vacuum environment, the present invention achieves great effects.

[0035] Also, it is preferable that the pressure buffering chamber be provided with a gas recovery port connected with a pipe for recovering gas from the atmospheric pressure groove; a gas feed port connected with a pipe for feeding gas by controlling the quantity of gas being fed so that the gas pressure in the pressure buffering chamber is a fixed pressure higher than the atmospheric pressure; and a gas leak port connected with a pipe for always discharging the gas in the pressure buffering chamber to the outside.

[0036] Thereby, since gas is always discharged to the outside through the gas leak port of the pressure buffering chamber, the inflow of impurities from the outside into the pressure buffering chamber can be prevented.

[0037] That is to say, impurities coming from the outside can be prevented from flowing into the atmospheric pressure groove, so that a decrease in the degree of vacuum of the vacuum environment can be prevented.

[0038] Also, as a gas fed into the pressure buffering chamber, high-purity nitrogen or dry air is preferable.

[0039] Thus, even if gas flows into the atmospheric pressure groove through the pressure buffering chamber, gas in the air containing much water does not flow in, and high-purity nitrogen flows into the pressure buffering chamber, so that there is no fear of degraded vacuum environment.

[0040] Also, in a gas recovering method for the hydrostatic gas bearing device, the gas pressure in a pressure buffering chamber provided on the outside of the hydrostatic gas bearing device is controlled so as to be a fixed pressure higher than the atmospheric pressure to always discharge gas from the pressure buffering chamber to the outside, and the gas recovered through the atmospheric pressure groove is also discharged to the outside through the pressure buffering chamber.

[0041] Thereby, since gas is always discharged to the outside through the gas leak port of the pressure buffering chamber, the inflow of impurities from the outside to the pressure buffering chamber can be prevented, and the gas released from the air pad can be recovered through the atmospheric pressure groove in the bearing.

[0042] That is to say, when the gas released from the air pad is recovered through the atmospheric pressure groove in the bearing, impurities coming from the outside can be prevented from flowing into the atmospheric pressure groove, so that a decrease in the degree of vacuum of the vacuum environment can be prevented.

Brief Description of Drawings

[0043]

FIG. 1 is a perspective view showing one embodiment of a hydrostatic bearing mechanism in accordance with the present invention;

FIG. 2 is a sectional view showing one embodiment of a coating on a guide shaft according to claim 4;

FIG. 3 is a graph showing a change in chamber

pressure at the time when a conventional hydrostatic gas bearing for vacuum is moved in a vacuum chamber;

FIG. 4 is a graph showing a result of the same measurement as that of FIG. 3 using a hydrostatic gas bearing according to claim 4;

FIG. 5 is a graph showing a result of the same measurement as that of FIG. 3 using a hydrostatic gas bearing according to claim 5;

FIG. 6 is a perspective view of a hydrostatic gas bearing device in accordance with one embodiment of the present invention;

FIG. 7 is a perspective view of a moving body in accordance with one embodiment of the present invention;

FIG. 8 is a plan view showing the inside of an upper plate member of the moving body shown in FIG. 7 and a sectional view thereof; and

FIG. 9 is a sectional view showing the relationship between a moving body and a guide shaft.

Best Mode for Carrying Out the Invention

[0044] A preferred embodiment according to this embodiment will be described below.

[0045] FIG. 1 is a perspective view showing one embodiment of a hydrostatic bearing mechanism for achieving the first object of the present invention. A moving body 1 is installed to a guide shaft 2a with a minute gap provided therebetween so as to be capable of being moved transversely without friction by the supply of a floatation gas. At each end, right and left, of the guide shaft 2a is provided a support 2b which is fixed to a surface plate, not shown. The supports 2b are not necessarily be fixed to the surface plate, but each of the supports 2b of hydrostatic bearing in accordance with the present invention located horizontally may be fixed to a moving body of another hydrostatic bearing (not shown) arranged in parallel in the direction perpendicular to the guide shaft 2a. In this case, the moving body of hydrostatic bearing located horizontally can be moved two-dimensionally. When being fixed to another moving body, the guide shaft ends may be fixed directly to the moving body without the supports 2b.

[0046] FIG. 2 is a sectional view showing one embodiment of a hydrostatic bearing in accordance with the present invention, which view shows an example in which a coating 3 is applied to the surface of the guide shaft 2a. The coating 3 was applied to the outer periphery of the guide shaft 2a using a material having a low gas adhesion probability.

[0047] Hereunder, the improvement in performance achieved by the present invention will be described.

[0048] A conventional hydrostatic gas bearing was placed in a vacuum chamber of about 4×10^{-4} Pa, and a change in the degree of vacuum in the vacuum chamber at the time when air is used as the floatation gas was shown in FIG. 3.

[0049] The ordinates represent the pressures in the vacuum chamber.

[0050] The abscissas represent times. First, recording was started in a state in which the bearing moving body stands still. After two seconds have elapsed, the movement of moving body was started (speed: 55 m/s), and then the moving body was stopped after the movement has been continued for about four seconds. The recording was finished 20 seconds after the measurement start (about 14 seconds after the stopping of moving body).

[0051] As shown in FIG. 3, when the conventional hydrostatic gas bearing was used, the chamber pressure began to increase simultaneously with the movement start and reached about 1×10^{-3} Pa. The chamber pressure did not return to the original pressure even 20 seconds after the measurement start.

[0052] The reason for this is that gas molecules adhere to the guide shaft, and the guide shaft is exposed in the vacuum chamber by the movement of moving body, so that the adhering gas molecules are released into the vacuum.

[0053] When the movement speed is further increased, the pressure in the vacuum chamber increases in proportion to the speed.

[0054] Next, a result of measurement made by using a hydrostatic gas bearing according to claim 4 was shown in FIG. 4. The surface of fixed body was coated with TiC, and measurement was made under the same conditions as those of FIG. 3. As the result, the increase in chamber pressure caused by movement reduced to an extent of not being detected.

[0055] The coating material is not limited to TiC. SiC may be used, or a metal such as aluminum may be deposited.

[0056] Contrarily, a result of measurement made by using a hydrostatic gas bearing according to claim 5 was shown in FIG. 5. As a material for fixed body, HIP processed alumina ceramics having a limited number of pores were used, and measurement was made under the same conditions as those of FIG. 3. As the result, the increase in chamber pressure reduced to about one-tenth of the conventional bearing (FIG. 3).

[0057] In this embodiment, since an air pad is provided on the moving body side, the surface treatment is done only on the surface of guide shaft. However, in the hydrostatic gas bearing having a construction in which the air pad is provided on the fixed body side, surface treatment on the surface of moving body is effective. Further, the surface treatment is not limited to either one of the guide shaft and the moving body, and can be done on both of the guide shaft and the moving body. As a concrete method for coating the ceramics surface with TiC, for example, a technique called plasma CVD, in which in a state in which ceramics are heated to 900°C, a mixture gas of TiCl_4 and CH_4 is made in a plasma state around the ceramics, by which TiC film is formed on the ceramics surface, can be used.

[0058] Also, as a concrete method for manufacturing ceramics having few pores by HIP, for example, a method in which fired alumina ceramics are held for 10 hours in argon gas having a high temperature of 1650°C and a high pressure of 100 MPa is used.

[0059] Next, a hydrostatic gas bearing device A for achieving the second object of the present invention is shown in FIGS. 6 to 9.

[0060] This hydrostatic gas bearing device A has a surface plate B and a hydrostatic gas bearing D provided in a vacuum chamber C. The pressure of vacuum environment in the vacuum chamber C in which the hydrostatic gas bearing D moves is required to be 10^{-3} to 10^{-4} Pa or lower. Further, movement in a vacuum environment of about 10^{-5} Pa or lower is also expected in the future.

[0061] The hydrostatic gas bearing D is formed of a moving body 1 and a guide shaft 2 (fixed body). As shown in FIGS. 7 to 9, the moving body 1 is formed with air pads 7 for releasing a gas supplied from the outside into a gap between the moving body 1 and the guide shaft 2. Further, around the air pad 7, there is provided an atmospheric pressure groove 8 for recovering the gas released into the gap and discharging it to the outside via a pipe 15 for atmospheric pressure groove.

[0062] Also, around the atmospheric pressure grooves 8, there is provided pressure reducing groove 9 for recovering the gas having not been recovered by the atmospheric pressure groove 8 and discharging it to the outside via a pipe.

[0063] Although the atmospheric pressure groove 8 and the pressure reducing groove 9 are provided in the moving body 1, the pipe for pressure reducing groove is also provided on the guide shaft 2 side. As shown in FIG. 8, exhaust connecting groove 9a communicating with the pressure reducing groove 9 is formed in the vertical direction in the figure. The guide shaft 2 is formed with an exhaust hole 22 for recovering gas through the pressure reducing groove 9 (including the exhaust connecting groove 9a) at a position opposed to the vertical exhaust connecting groove 9a. Therefore, even if the moving body 1 moves in the range from a position shown in FIG. 9(B) to a position shown in FIG. 9(C), the exhaust hole 22 communicates with the exhaust connecting groove 9a, so that gas in the pressure reducing groove 9 (including the exhaust connecting groove 9a) can be exhausted through the exhaust hole 22.

[0064] By the above-described configuration, by using the atmospheric pressure grooves 8 surrounding the air pads 7 of the hydrostatic gas bearing D, and further by using a labyrinth exhaust mechanism surrounding the atmospheric pressure grooves 8, the quantity of gas flowing out into the vacuum chamber C is kept small to an extent of having no influence on the degree of vacuum of the vacuum chamber C. A plurality of pressure reducing grooves 9 may be provided according to the required degree of vacuum of operation environment to improve the recovery rate of gas.

[0065] Also, although the case where the pipe for pressure reducing groove is provided within the guide shaft 2 has been shown, the pipe can be provided in the moving body 1. For example, in order that the moving body 1 is made smaller in size and the pipe is not restricted by the movement distance of the moving body 1, the pipe is preferably provided in the moving body 1 if the pumping performance is sacrificed to some extent. In this case, the above-mentioned vertical pressure reducing groove 9 is unnecessary.

[0066] However, since gas is recovered by an evacuator, the diameter of the pipe for pressure reducing groove is, in general, considerably larger than the diameter of the pipe connected to the air pad 7 or the atmospheric pressure groove 8. In this case, if the pipe for pressure reducing groove is connected to the moving body 1, the pipe works as a source of resistance and vibration, which may exert an adverse influence on the high movement accuracy required by the moving body 1. Therefore, the pipe for pressure reducing groove should usually be provided on the guide shaft 5 side.

[0067] In effect, it should be determined whether the pipe for pressure reducing groove is provided in the moving body 1 or in the guide shaft 2 considering the size and movement distance of the moving body 1, the influence exerted on the moving body 1 as resistance by the pipe in the case where the pipe is connected to the moving body 1, and other factors.

[0068] In FIG. 6, a pipe and a feed pump for feeding gas to the air pad 7, the pipe for pressure reducing groove, and the evacuator are omitted.

[0069] As shown in FIG. 6, for this hydrostatic bearing device, a pressure buffering chamber 10 on the outside of the vacuum chamber C is connected to a pipe 15b for atmospheric pressure groove for discharging the gas recovered through the atmospheric pressure groove 8 to the outside to prevent gas from flowing backward from the outside to the atmospheric pressure groove 8 through the pipe 15b for atmospheric pressure groove.

[0070] The pressure buffering chamber 10 is provided with a gas recovery port 11, a gas feed port 12, and a gas leak port 13.

[0071] The gas recovery port 11 is connected with the pipe 15b for atmospheric pressure groove for recovering gas from the atmospheric pressure groove 8 through an introduction port 14 in the vacuum chamber C.

[0072] Also, the gas feed port 12 is connected with a gas feed pipe 15a for feeding gas by controlling the quantity of gas being fed so that the gas pressure in the pressure buffering chamber 10 is a fixed pressure higher than the atmospheric pressure. A pressure gage 16 is provided to measure the internal pressure of the pressure buffering chamber 10, and also a mass-flow controller 17 is connected in the gas feed pipe 15a. A signal is sent from the pressure gage 16 to the mass-flow controller 17 via a signal cable 20 so that the pressure in the pressure buffering chamber 10 is about 10% higher than the atmospheric pressure to control the flow rate

of gas being fed. Thereby, the flow rate of nitrogen flowing from a nitrogen cylinder 18 into the pressure buffering chamber 10 through the gas feed pipe 15a is controlled.

[0073] Also, the gas leak port 13 is connected with a pipe for always discharging the gas in the pressure buffering chamber 10 to the outside. It is preferable that a leak valve 19 provided in the pressure buffering chamber 10 be throttled properly to regulate the flow rate of nitrogen flowing out from the leak valve 19 to the outside so as to be about 5 to 10 liters/minute. Thereby, the quantity of nitrogen being consumed can be kept small while the air is prevented from flowing from the leak valve 19 into the pressure buffering chamber 10.

[0074] The nitrogen supplied from the nitrogen cylinder 18 is preferably of high purity to prevent the degree of vacuum around the bearing from decreasing even if the gas in the pressure buffering chamber 10 flows backward to the atmospheric pressure groove 8. The purity of the high-purity nitrogen is preferably 99.99% or higher. Especially when the hydrostatic gas bearing is used in a high vacuum of about 10^{-5} Pa, the purity of nitrogen is preferably 99.9999% or higher.

[0075] Also, the gas fed into the pressure buffering chamber 10 through the gas feed pipe 15a may be dry air. In this case, the dry air preferably has a dew point of -30°C or lower so that the degree of vacuum does not decrease even if the gas in the pressure buffering chamber 10 flows backward to the atmospheric pressure groove 8.

[0076] Next, a gas recovering method for a hydrostatic gas bearing 4 for use in the above-described vacuum environment will be described in due succession.

[0077] First, a high-pressure gas is released from the air pad 7 provided on the moving body 1 into the gap between the guide shaft 2 and the moving body 1. The moving body 1 and the guide shaft 2 are made in a non-contact state by the static force of the released gas, so that the moving body 1 can move along the guide shaft 2 with frictional resistance being scarcely encountered.

[0078] Next, the gas released into the above-mentioned gap is recovered through the atmospheric pressure groove 8 provided around the air pad 7.

[0079] At this time, the gas pressure in the pressure buffering chamber 10 provided on the outside of the hydrostatic gas bearing device A is controlled so as to be a fixed pressure higher than the atmospheric pressure (for example, a pressure 10% higher than the atmospheric pressure), by which gas is always discharged from the pressure buffering chamber 10 to the outside, and also the gas recovered through the atmospheric pressure groove 8 is also discharged to the outside through the pressure buffering chamber 10. Thereby, the outside air is prevented from flowing backward into the atmospheric pressure groove 8.

[0080] Further, in order to decrease the gas released in the vacuum from the end of the moving body 1, the gas that has not been recovered through the atmospheric

ic pressure groove 8 is recovered through the pressure reducing groove 9 provided around the atmospheric pressure groove 8.

[0081] In the above-described process, the atmospheric pressure groove 8 communicates with the air only through the leak valve 19 provided in the pressure buffering chamber 10. Since nitrogen of about 5 to 10 liters/minute flows out through the leak valve 19, the inflow of impurities from the air can be restrained. Thereupon, the gas flowing into the atmospheric pressure groove 8 is only the gas flowing in through the air pad 7 or the nitrogen supplied from the nitrogen cylinder 18 through the pressure buffering chamber 10, so that a trouble such as an increase in the quantity of gas being discharged from the bearing caused by the inflow of impurities can be prevented.

Industrial Applicability

[0082] As described above, in the present invention, since surface treatment is done on the surface of the guide shaft of fixed body and/or the surface of the moving body to decrease the quantity of adhering gas, there can be provided a hydrostatic gas bearing capable of restraining the increase in the quantity of gas being discharged at the time of movement.

[0083] Also, the surface of the guide shaft of fixed body and/or the surface of the moving body is coated with a material having a lower gas adhesion probability, especially, coating is performed on an Al_2O_3 surface by physically depositing TiC having electric conductivity. Therefore, there can be provided a hydrostatic gas bearing capable of keeping the quantity of adhering H_2O , which especially poses a problem of adhesion of gas molecules, about two orders of magnitude smaller.

[0084] Also, the guide shaft of fixed body and/or the moving body is manufactured of high-density ceramics having few pores in the surface thereof. Therefore, there can be provided a hydrostatic gas bearing capable of reducing the increase in the quantity of gas being discharged caused by the influence of pores.

[0085] Also, as a floatation gas of hydrostatic gas bearing, an inert gas such as argon, which has less interaction with a solid and less adhesion to the surface, is used. Therefore, there can be provided a hydrostatic gas bearing capable of decreasing the quantity of gas being discharged at the time of movement.

[0086] Further, according to the hydrostatic gas bearing device in accordance with the present invention, the pressure in the atmospheric pressure groove in the bearing in a vacuum environment is kept fixed, and the inflow of impurities such as water content of gas caused by the backward flow of outside gas into the atmospheric pressure groove through the pipe for atmospheric pressure groove is inhibited, by which a decrease in the degree of vacuum in the vacuum environment can be prevented.

Claims

1. A hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to said moving body, **characterized in that** the surface of a guide shaft of said fixed body is subjected to processing for reducing adhesion of gas molecules. 5
2. A hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to said moving body, **characterized in that** the surface of said moving body is subjected to processing for reducing adhesion of gas molecules. 10
3. A hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to said moving body, **characterized in that** the surface of a guide shaft of said fixed body and the surface of said moving body are subjected to processing for reducing adhesion of gas molecules. 15
4. The hydrostatic gas bearing according to any one of claims 1 to 3, **characterized in that** as a method of processing for reducing adhesion of gas molecules, a coating with a material having a low adhesion probability of gas molecules is used. 20
5. The hydrostatic gas bearing according to claim 4, **characterized in that** as the material having a low adhesion probability of gas molecules, a material having electric conductivity is used. 25
6. The hydrostatic gas bearing according to claim 5, **characterized in that** as the material having a low adhesion probability of gas molecules, TiC is used. 30
7. A hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to said moving body, **characterized in that** a guide shaft of said fixed body is manufactured of ceramics having few pores. 35
8. A hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to said moving body, **characterized in that** said moving body is manufactured of ceramics having few pores. 40
9. A hydrostatic gas bearing for use in a vacuum, which is formed of a moving body and a fixed body opposed to said moving body, **characterized in that** a guide shaft of said fixed body and the moving body are manufactured of ceramics having few pores. 45
10. The hydrostatic gas bearing according to any one of claims 7 to 9, **characterized in that** said ceramics having few pores are manufactured by HIP processing. 50
11. The hydrostatic gas bearing according to any one of claims 1 to 10, **characterized in that** as a floatation gas, an inert gas such as argon is used. 55
12. A hydrostatic gas bearing device for use in a vacuum environment, in which
 - a guide shaft and a moving body moving along said guide shaft are provided in a vacuum chamber;
 - said moving body is formed with an air pad for releasing gas fed from the outside into a gap between said moving body and said guide shaft;
 - an atmospheric pressure groove, which recovers the gas released into said gap and discharges the recovered gas to the outside through a pipe, is provided around said air pad; and
 - a pressure reducing groove, which recovers the gas having not been recovered by said atmospheric pressure groove and discharges the recovered gas to the outside through a pipe, is provided around said atmospheric pressure groove, **characterized in that**
 - in a pipe for discharging the gas recovered through said atmospheric pressure groove to the outside, there is provided a pressure buffering chamber, in which the internal gas pressure thereof is a fixed pressure higher than the atmospheric pressure so that gas does not flow backward from the outside to said atmospheric pressure groove through said pipe.
13. The hydrostatic gas bearing device for use in a vacuum environment according to claim 12, **characterized in that** said pressure buffering chamber has:
 - a gas recovery port connected with a pipe for recovering gas from said atmospheric pressure groove;
 - a gas feed port connected with a pipe for feeding gas by controlling the quantity of gas being fed so that the gas pressure in said pressure buffering chamber is a fixed pressure higher than the atmospheric pressure; and
 - a gas leak port connected with a pipe for always discharging the gas in said pressure buffering chamber to the outside.
14. The hydrostatic gas bearing device for use in a vacuum environment according to claim 13, **characterized in that** the gas fed into said pressure buffering chamber is nitrogen with high purity.
15. The hydrostatic gas bearing device for use in a vacuum environment according to claim 14, **characterized in that** the gas fed into said pressure buffering chamber is nitrogen with high purity.

uum environment according to claim 13, **characterized in that** the gas fed into said pressure buffering chamber is dry air.

16. The hydrostatic gas bearing device for use in a vacuum environment according to claim 12, **characterized in that** at least either one of the surface of said guide shaft and the surface of said moving body is subjected to processing for reducing adhesion of gas molecules. 5
10
17. The hydrostatic gas bearing device according to claim 16, **characterized in that** as a method of processing for reducing adhesion of gas molecules, a coating with a material having a low adhesion probability of gas molecules is used. 15
18. The hydrostatic gas bearing device according to claim 17, **characterized in that** as the material having a low adhesion probability of gas molecules, a material having electric conductivity is used. 20
19. The hydrostatic gas bearing device according to claim 18, **characterized in that** as the material having a low adhesion probability of gas molecules, TiC is used. 25
20. The hydrostatic gas bearing device according to claim 12, **characterized in that** at least either one of said guide shaft and said moving body is manufactured of ceramics having few pores. 30
21. The hydrostatic gas bearing device according to claim 20, **characterized in that** said ceramics having few pores are manufactured by HIP processing. 35
22. The hydrostatic gas bearing device according to any one of claims 12 to 21, **characterized in that** as a floatation gas, an inert gas such as argon is used. 40
23. A gas recovering method for a hydrostatic gas bearing device for use in a vacuum environment, in which
 - gas is released from an air pad provided on a moving body into a gap between a guide shaft and said moving body; 45
 - the gas released into said gap is recovered through an atmospheric pressure groove provided around said air pad; and 50
 - the gas having not been recovered by said atmospheric pressure groove is recovered through a pressure reducing groove provided around said atmospheric pressure groove, **characterized in that**
 - the gas pressure in a pressure buffering chamber provided on the outside of said hydrostatic gas bearing device is controlled so as to be a fixed pressure higher than the atmospheric pressure to 55

always discharge gas from said pressure buffering chamber to the outside, and the gas recovered through said atmospheric pressure groove is also discharged to the outside through said pressure buffering chamber.

FIG. 1

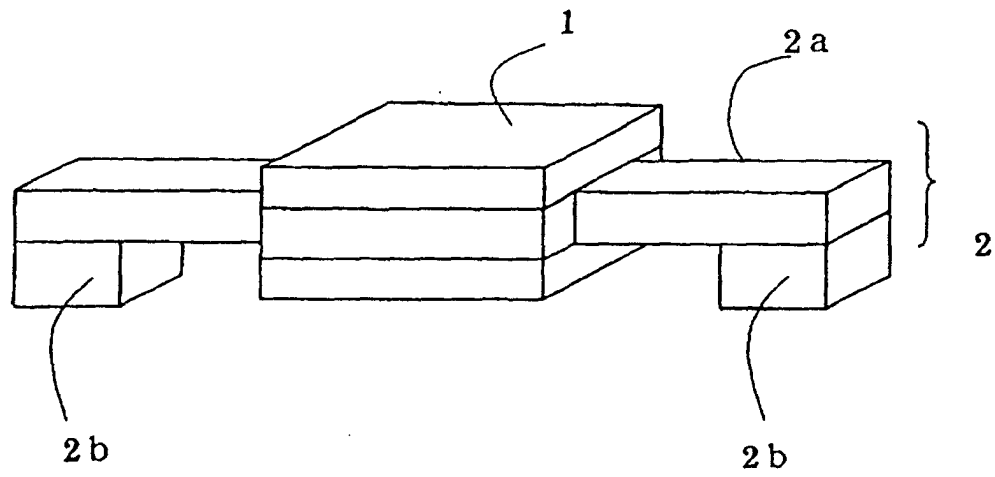


FIG. 2

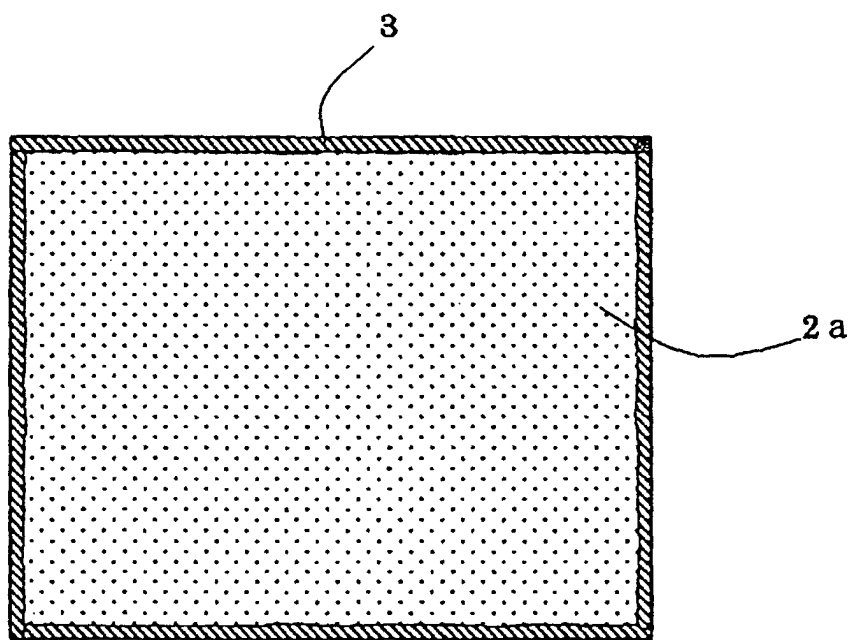


FIG. 3

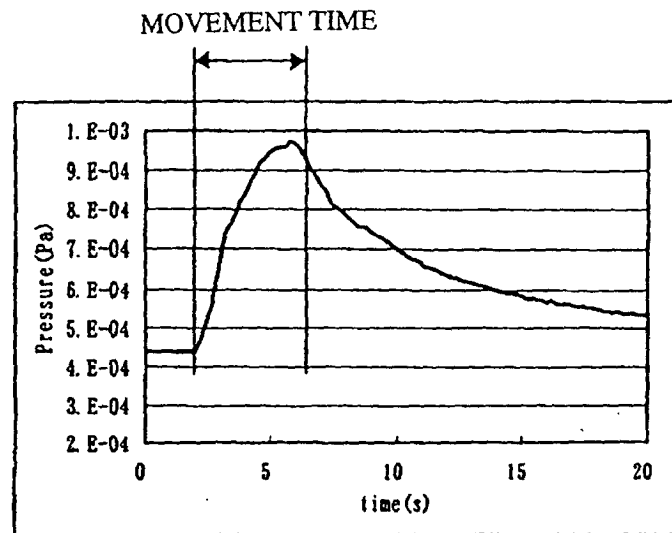


FIG. 4

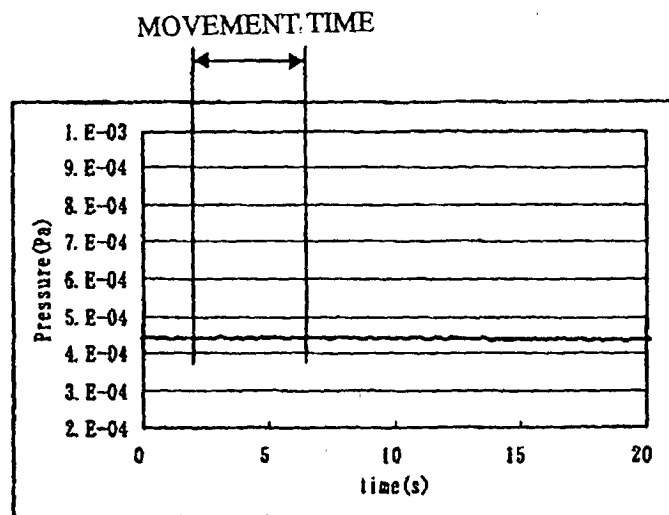


FIG. 5

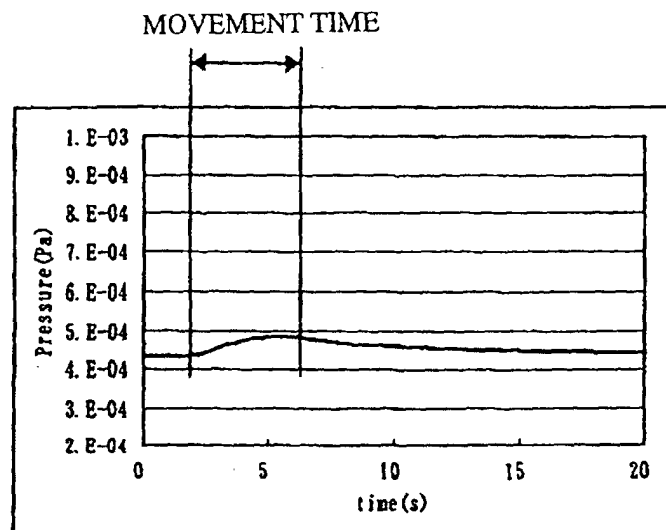


FIG. 6

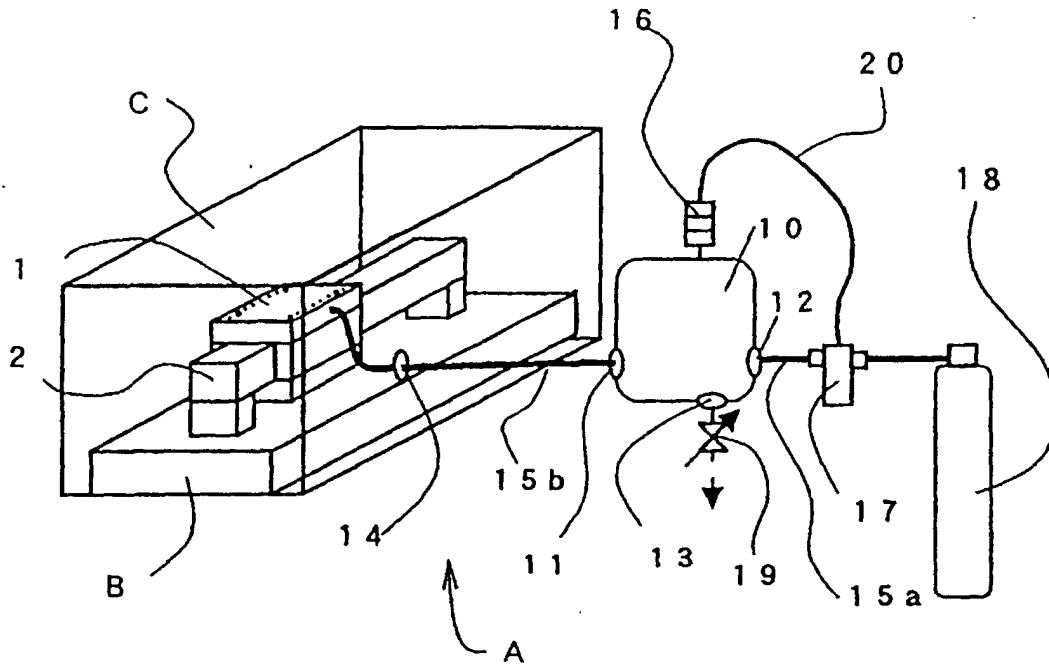


FIG. 7

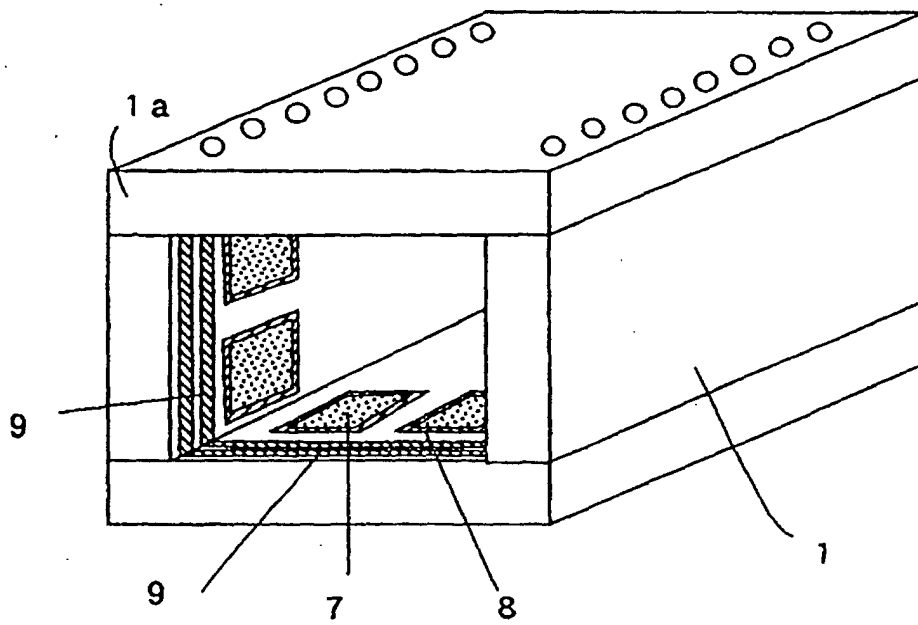


FIG. 8

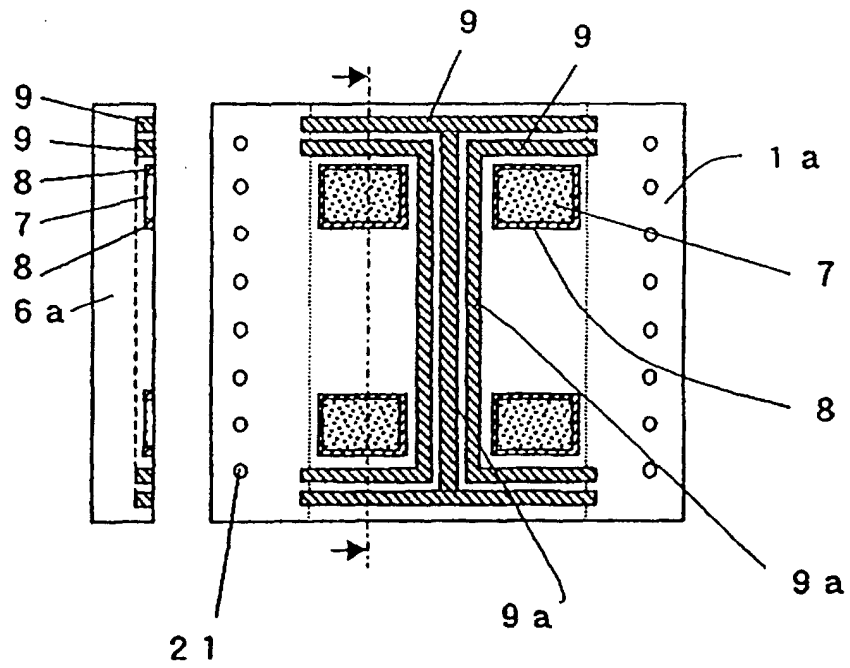


FIG. 9 (A)

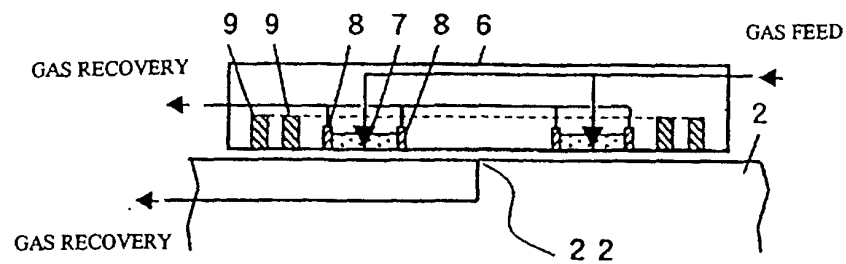


FIG. 9 (B)

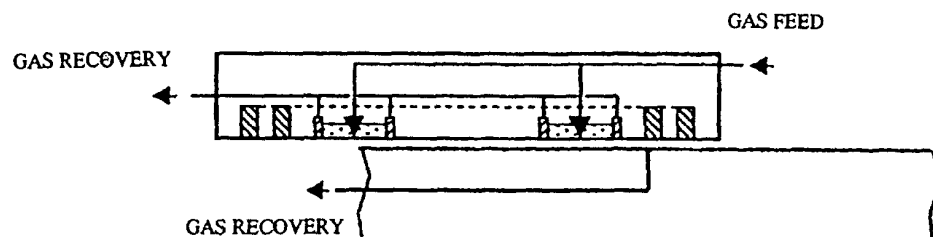
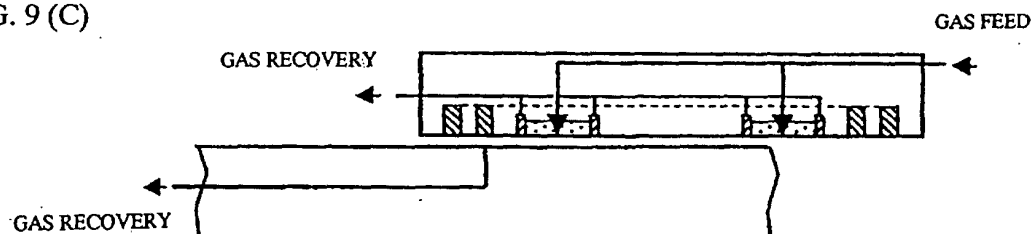


FIG. 9 (C)



INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP01/00582

A. CLASSIFICATION OF SUBJECT MATTER Int.Cl. ⁷ F16C32/06		
According to International Patent Classification (IPC) or to both national classification and IPC		
B. FIELDS SEARCHED		
Minimum documentation searched (classification system followed by classification symbols) Int.Cl. ⁷ F16C32/06, G03F7/20, G03F9/00, H01L21/68		
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Jitsuyo Shinan Koho 1926-1996 Toroku Jitsuyo Shinan Koho 1994-2001 Kokai Jitsuyo Shinan Koho 1971-2001 Jitsuyo Shinan Toroku Koho 1996-2001		
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	JP, 2-212624, A (Canon Inc.), 23 August, 1990 (23.08.90), Fig. 1 (Family: none)	1-23
A	Microfilm of the specification and drawings annexed to the request of Japanese Utility Model Application No. 100239/1988 (Laid-open No.21328/1990), (Kyocera Corporation), 13 February, 1990 (13.02.90), description, page 4, line 12 to page 5, line 1 (Family: none)	1-23
☐ Further documents are listed in the continuation of Box C. ☐ See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier document but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 19 April, 2001 (19.04.01)		Date of mailing of the international search report 01 May, 2001 (01.05.01)
Name and mailing address of the ISA/ Japanese Patent Office		Authorized officer
Facsimile No.		Telephone No.

Form PCT/ISA/210 (second sheet) (July 1992)